

CMP Waste Treatment with a Forced-Flow Electrophoresis Device

(Subtask A-4-1)

Jamie L. Ludke

Milan Bier

James C. Baygents

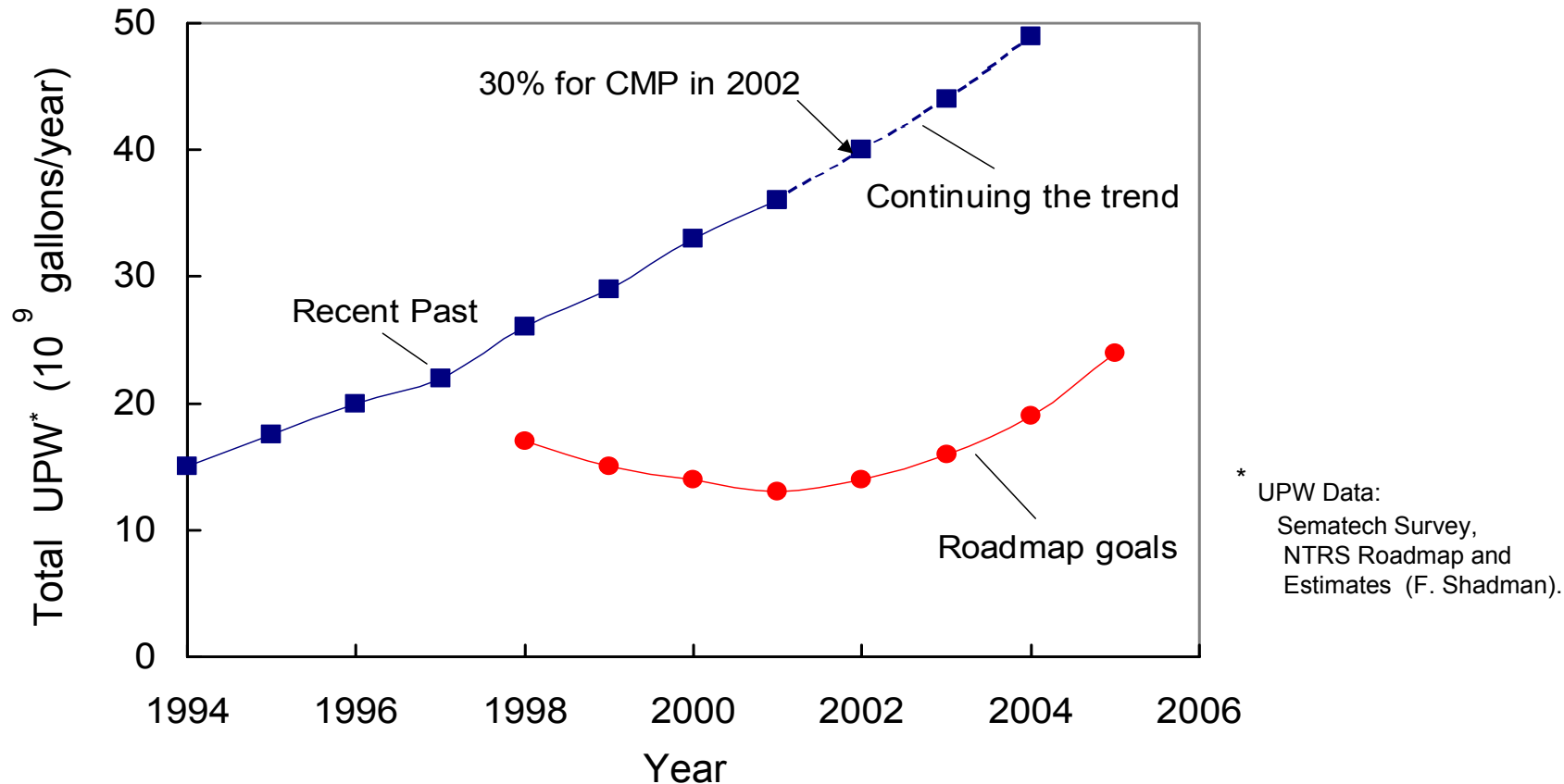
The University of Arizona

Outline

- Motivation
- Description of Forced-Flow Electrophoresis
- Results
- Additional Research
- Potential Transfer of Technology
- Concluding Remarks

ITRS Technology Barrier: Sustainability vs. Resource Consumption

In 2002 CMP will constitute approximately 30% of UPW usage.
UPW consumption continues to exceed Roadmap goals.



ITRS Technology Barrier: Sustainability vs. Resource Consumption (cont.)

Current Trend[†]

- One CMP tool requires:
 - 7,000 gallons of UPW per day
 - 12,000 gallons feed water per day
- As device linewidths shrink additional CMP will be required

ITRS Goals[‡]

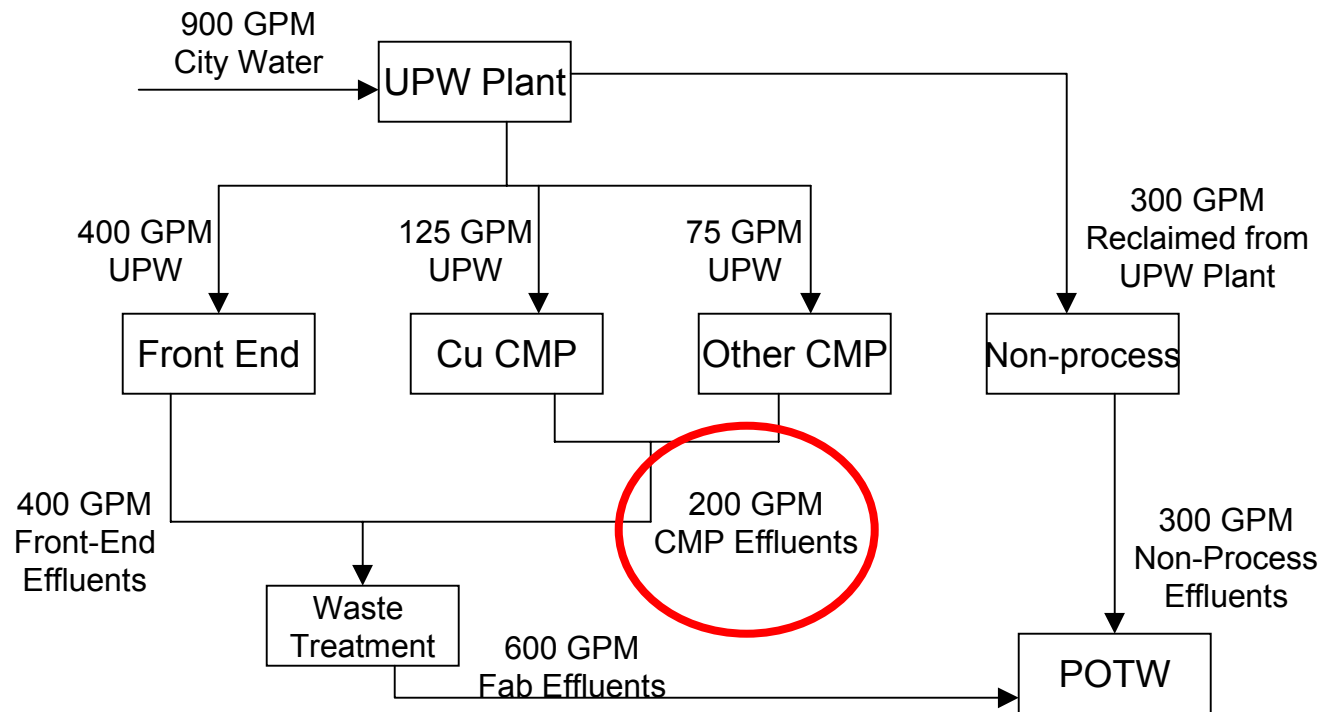
- Net feed water consumption drop from 13 gal/in² (of silicon) to 2 gal/in² by 2008
- Obtain environmental sustainability through waste management

[†] Corlett, G. *Advancing Applications in Contamination Control* 2000, 3(11), 9.

[‡] Semiconductor Industry Association *International Technology Roadmap for Semiconductors: 1999 edition*; International SEMATECH: Austin, Texas, 1999; pg. 253.

ITRS Technology Barrier: Waste Production vs. Environmental Regulations

Single fabrication plant produces 200 GPM of CMP effluent.[†]



[†] Maag, Benoit, "Copper CMP Effluent Flow in a Semiconductor Facility", NSF/SRC ERC for Environmentally Benign Semiconductor Manufacturing TeleSeminar, April 6, 2000

ITRS Technology Barrier:

Waste Production vs. Environmental Regulations (cont.)

Waste Characteristics[†]

- 50-5000 ppm total suspended solids
- 0.1-50 ppm soluble copper

Environmental Regulations[†]

Waste must be reduced to the following levels prior to discharge to waste treatment system:

- < 5 ppm total suspended solids
- 0.1-2 ppm soluble copper
- Regulations vary according to location.
 - San Jose Code Limitations:[‡] Cu = 2.7 ppm
 - Austin Code Limitations:[‡] Cu = 1.9 ppm

[†] Raghavan, S. *Treatment of CMP Wastes*; Fourth Year Annual Report of the NSF/SRC Engineering Research Center for Environmentally Benign Semiconductor Manufacturing on Grant EEC-9528813; University of Arizona: Tucson, Arizona, 2000; Vol. II, pg. 30.

[‡] Corlett, G. *Advancing Applications in Contamination Control* December 1998, pg. 19.

Forced-Flow Electrophoresis (FFE)

Research Objectives

- Liquid/solid separation
 - good performance at high concentrations; retard filter cake buildup
 - create possibilities for water recycle/reuse
- Copper removal from waste stream

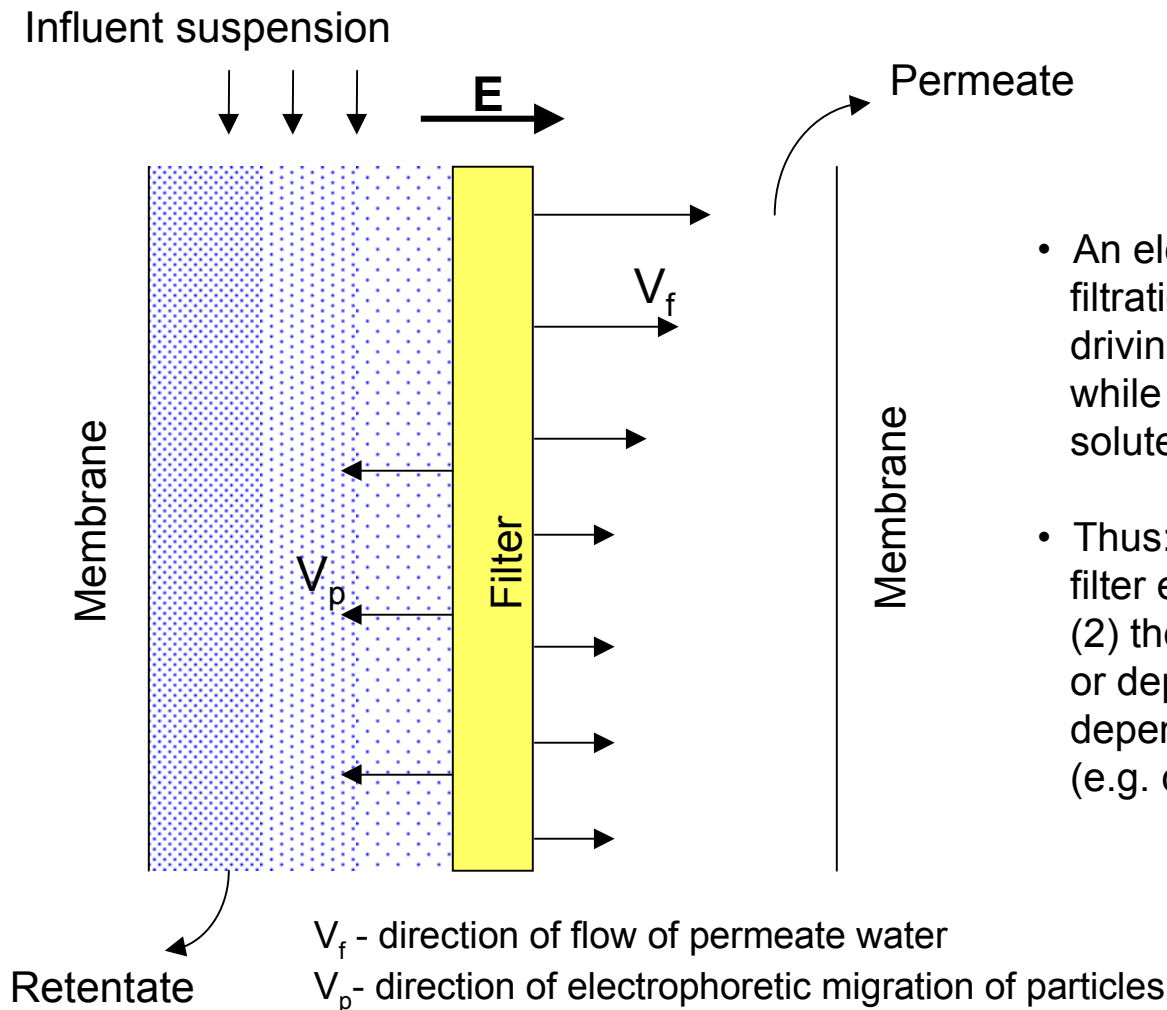
ESH Impact

- Recovery and recycle of water
- Help achieve ITRS goals for environmental sustainability through waste management
- Compliance with environmental regulations for waste streams

Outline

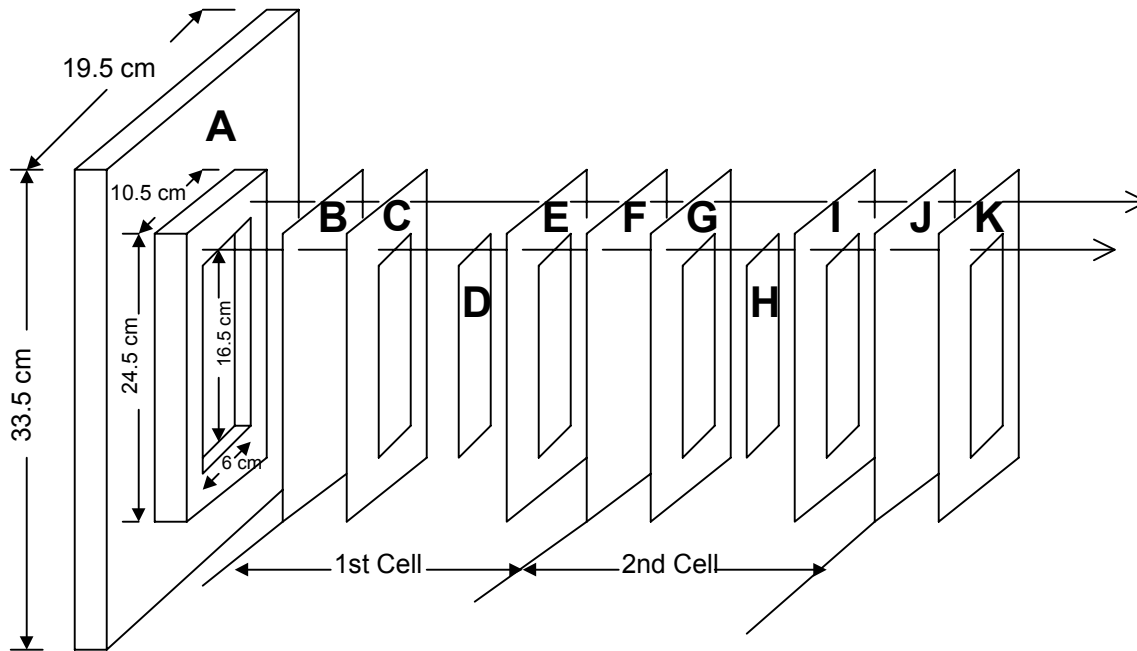
- Motivation
- Description of Forced-Flow Electrophoresis
- Results
- Additional Research
- Potential Transfer of Technology
- Concluding Remarks

FFE: Cross-Flow Filtration with Electric Field



- An electric field E enhances cross-flow filtration process by electrophoretically driving particles away from filter surface, while driving electro dialysis of ionic solutes (e.g. Cu)
- Thus: (1) filter cake is suppressed and filter effectiveness maintained; and (2) the permeate is either enriched with, or depleted of, ionic solutes (including Cu), depending on the type of membrane used (e.g. cation exchange or anion exchange)

Expanded FFE Cell Assembly

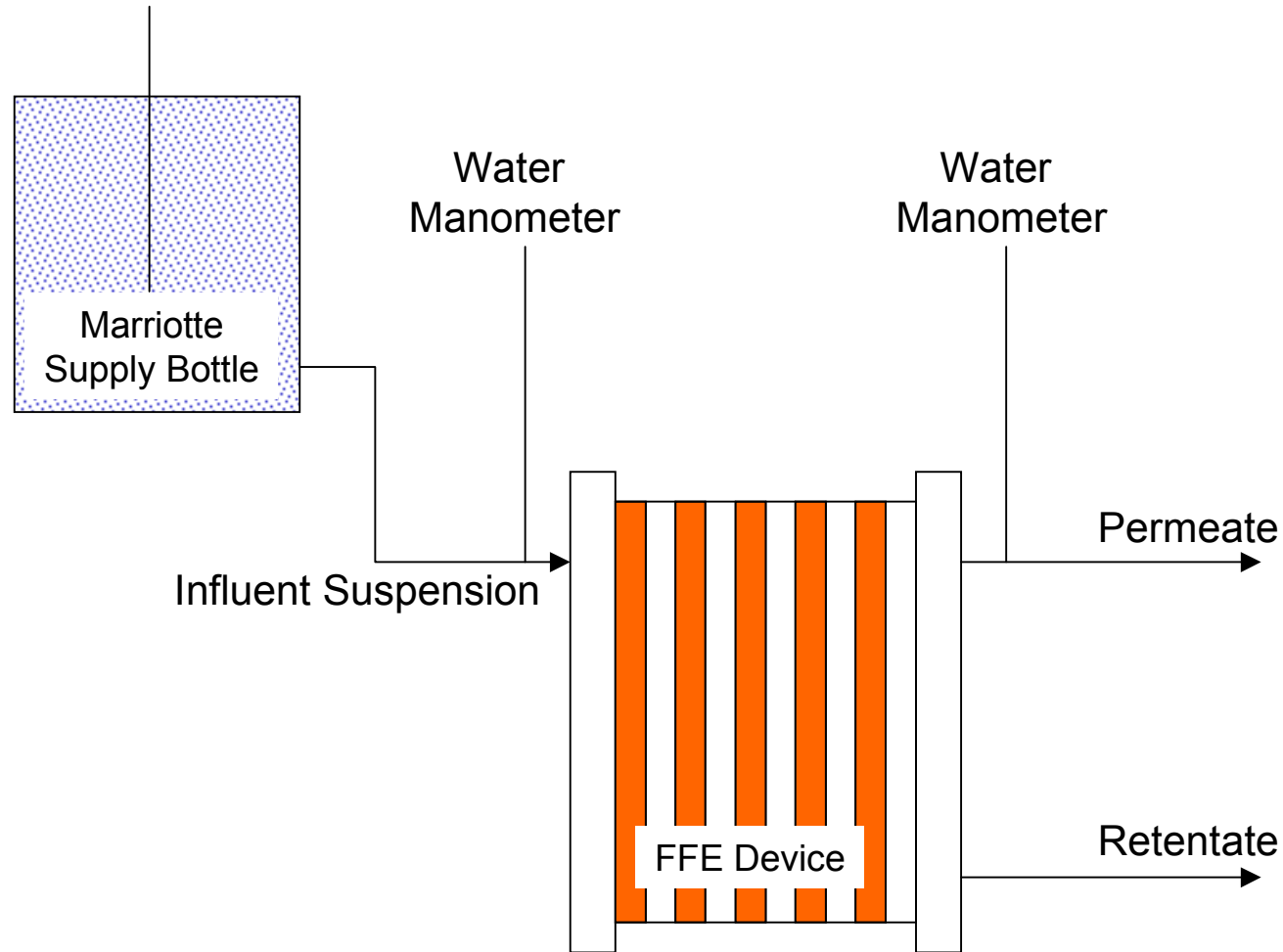


- A** End plate with Platinum Electrode
- B** Dialyzing Membrane
- C** Input Spacer for 1st Cell
- D** Micro Filter (Whatman, 20 μm)
- E** Output Spacer for 1st Cell
- F** Dialyzing Membrane
- G** Input Spacer for 2nd Cell
- H** Micro Filter (Whatman, 20 μm)
- I** Output Spacer for 2nd Cell
- J** Dialyzing Membrane
- K** Input Spacer for 3rd Cell

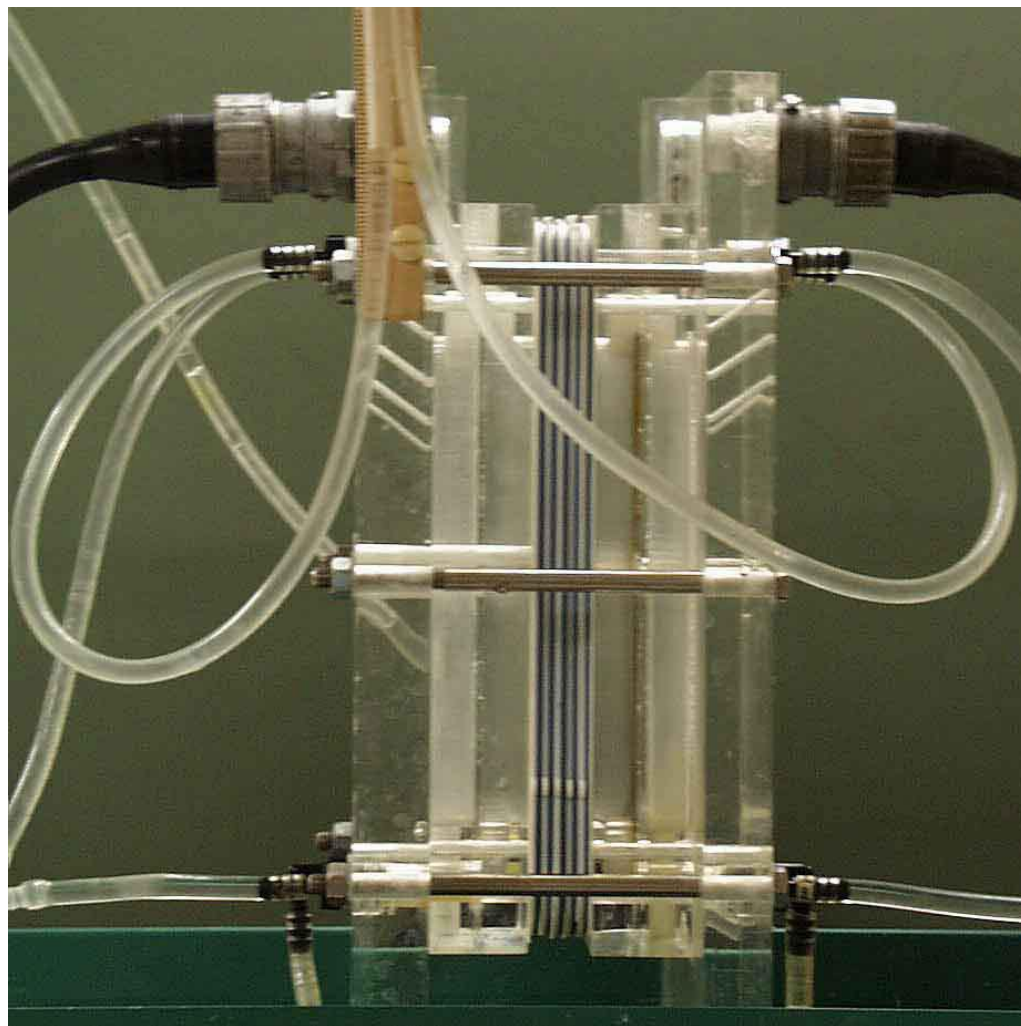
Device Components and Operating Conditions

- Electrodes: platinum
- Membranes: regenerated cellulose
(weak cation exchange properties)
- Filters: Whatman[®], 20 μm porosity
- Influent flow rate: 80 ml/min
- Permeate and retentate flow rate: 40 ml/min
- Effective volume: 180 ml

Entire FFE Apparatus



FFE Apparatus



- FFE method developed by:
Bier, M. et al., **1959**
- Additional research on FFE:
Henry, et al., **1977**
Wakeman, et al., **1987**
- Review of FFE
Huotari, et al., **1999**

Outline

- Motivation
- Description of Forced-Flow Electrophoresis
- Results
- Additional Research
- Potential Transfer of Technology
- Concluding Remarks

CMP Waste Characteristics

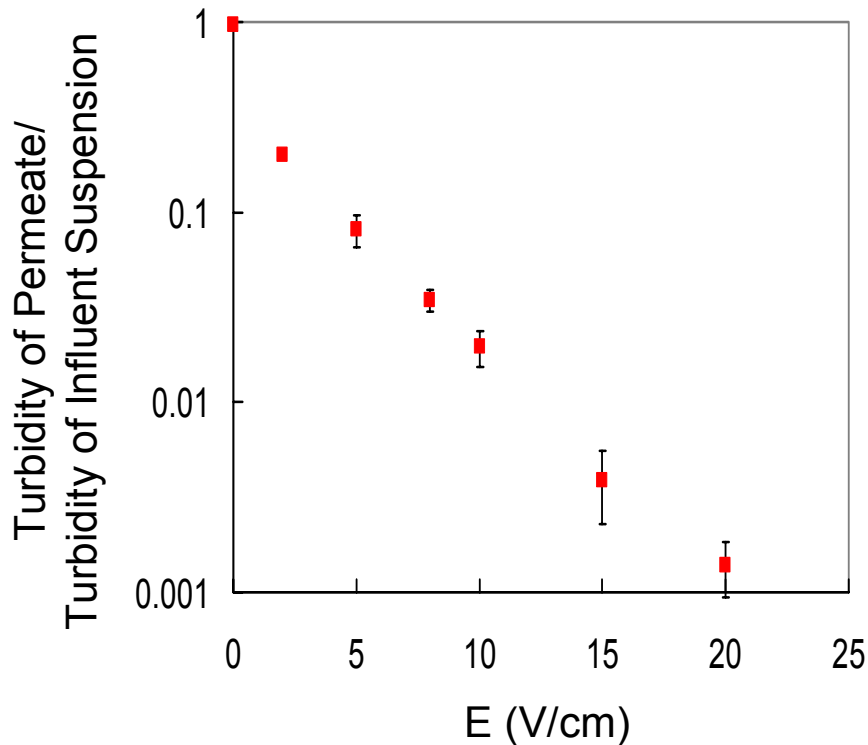
| Waste Stream | Turbidity (NTU) | Conductivity ($\mu\text{S/cm}$) | pH | Cu ⁺⁺ Conc. (ppm) |
|-------------------|------------------|-----------------------------------|------|------------------------------|
| Model Oxide | 450 [†] | 230 | 10.5 | — |
| Texas Instruments | 1550 | 160 | 9.0 | — |
| Model Copper | 410 [‡] | 570 | 5.0 | 20 |

[†] 1000 ppm Klebosol[®] colloidal silica; mean particle size, 80 nm

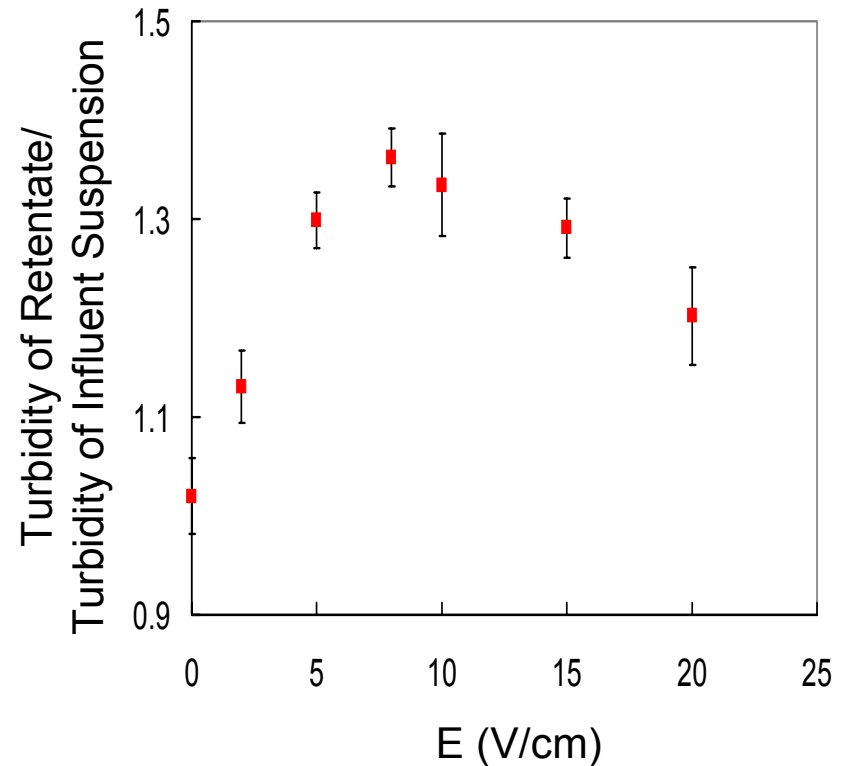
[‡] 900 ppm Klebosol[®] colloidal silica; mean particle size, 80 nm

Electrophoretic Filtration of Particles for Model Oxide CMP Waste

Permeate



Retentate



Influent Suspension Characteristics:

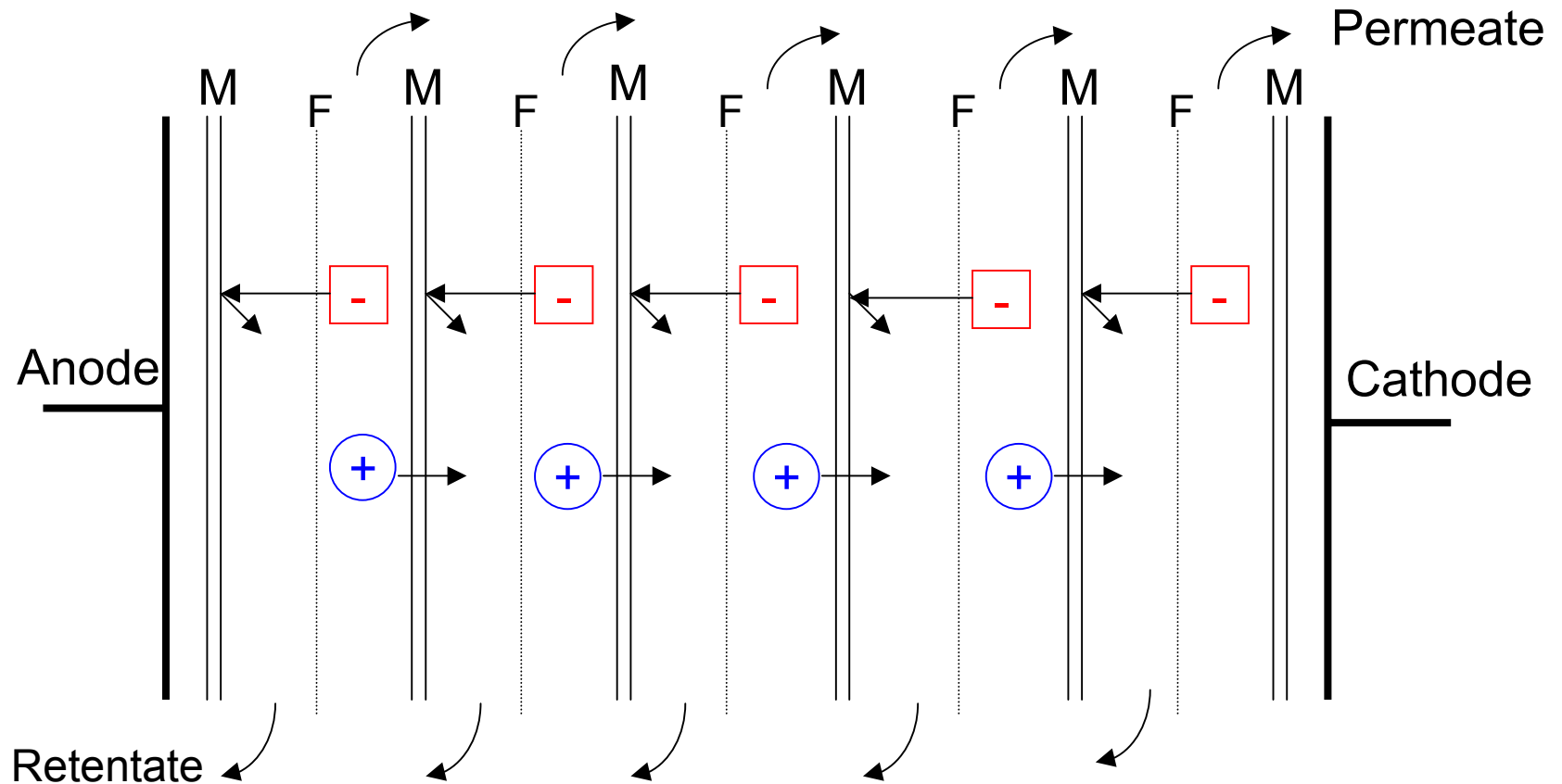
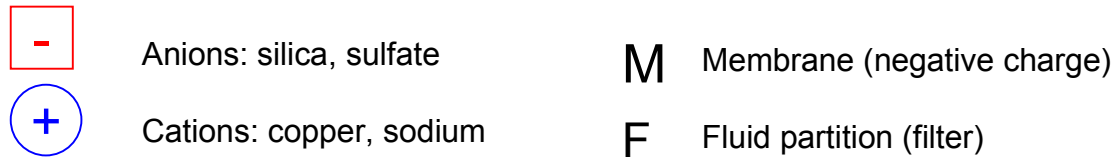
[SiO₂] = 1000 ppm

Turbidity = 450 NTU

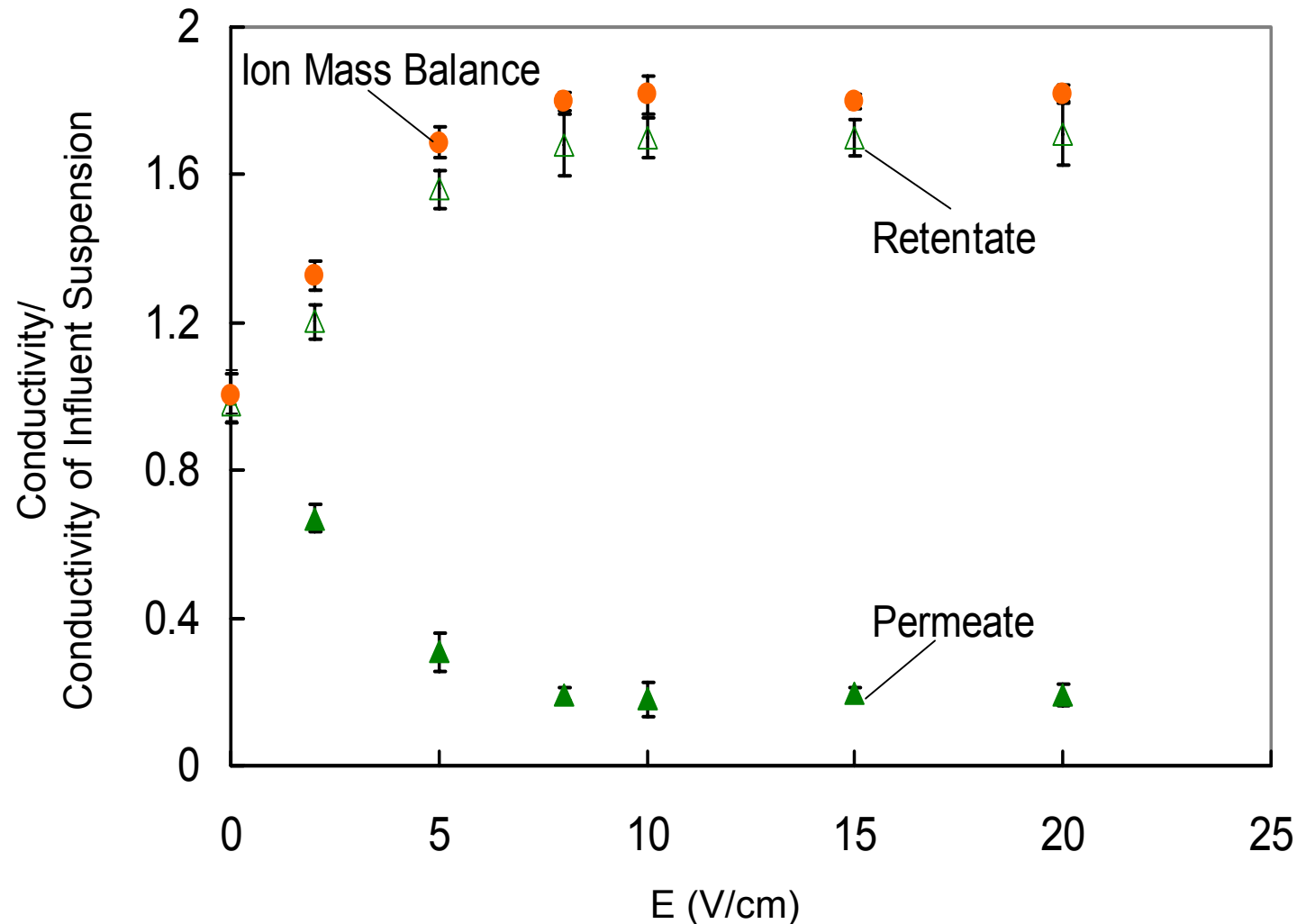
Conductivity = 230 μ S/cm

pH = 10.5

Electrodialysis Mechanism

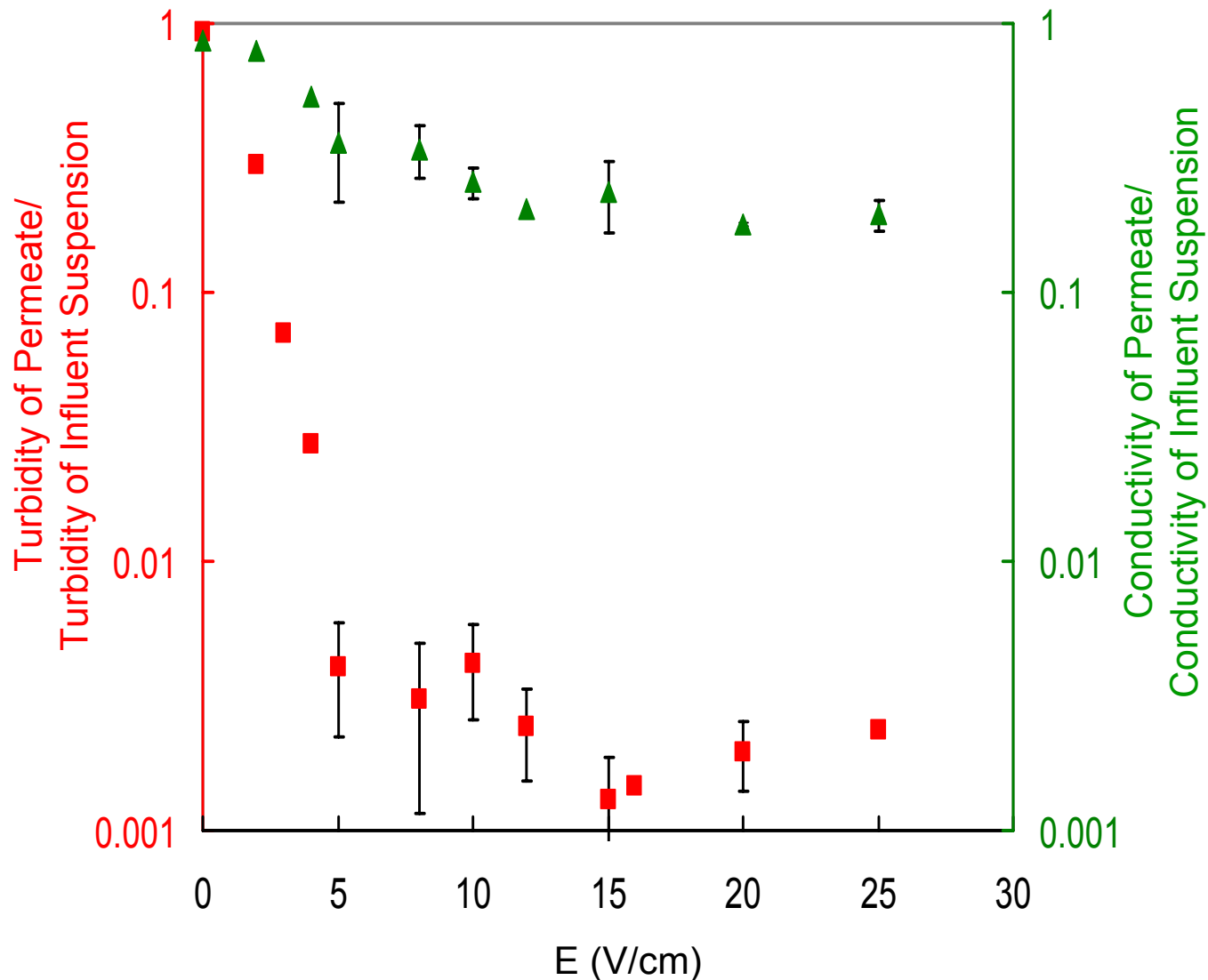


Electrodialysis of Ionic Solutes for Model Oxide CMP Waste



Influent Suspension
Characteristics:
[SiO₂] = 1000 ppm
Turbidity = 450 NTU
Conductivity = 230 μ S/cm
pH = 10.5

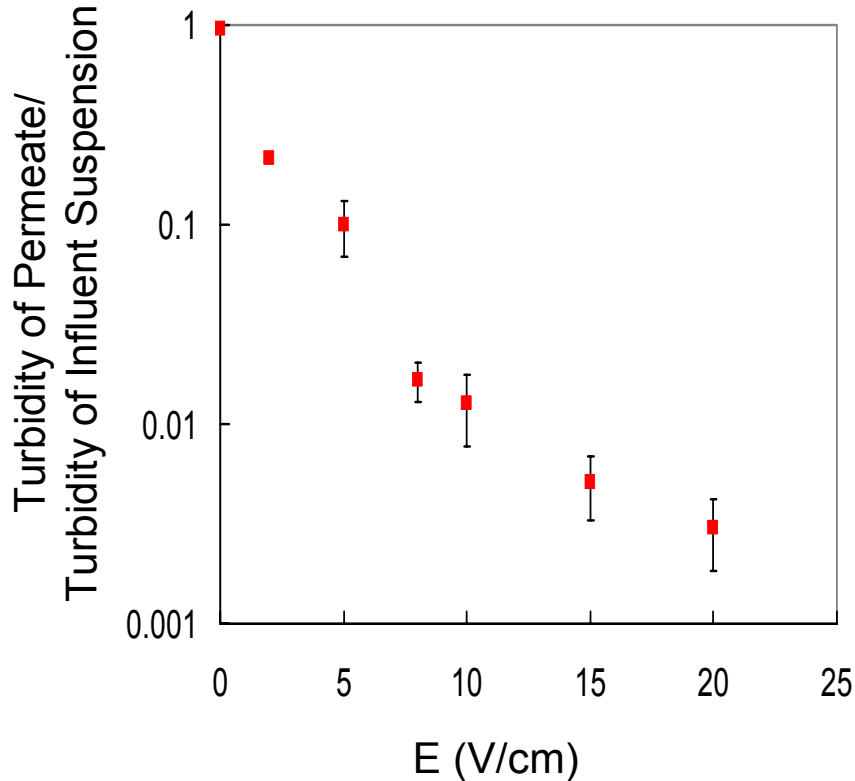
FFE of Industrial Oxide CMP Waste from Texas Instruments Inc.



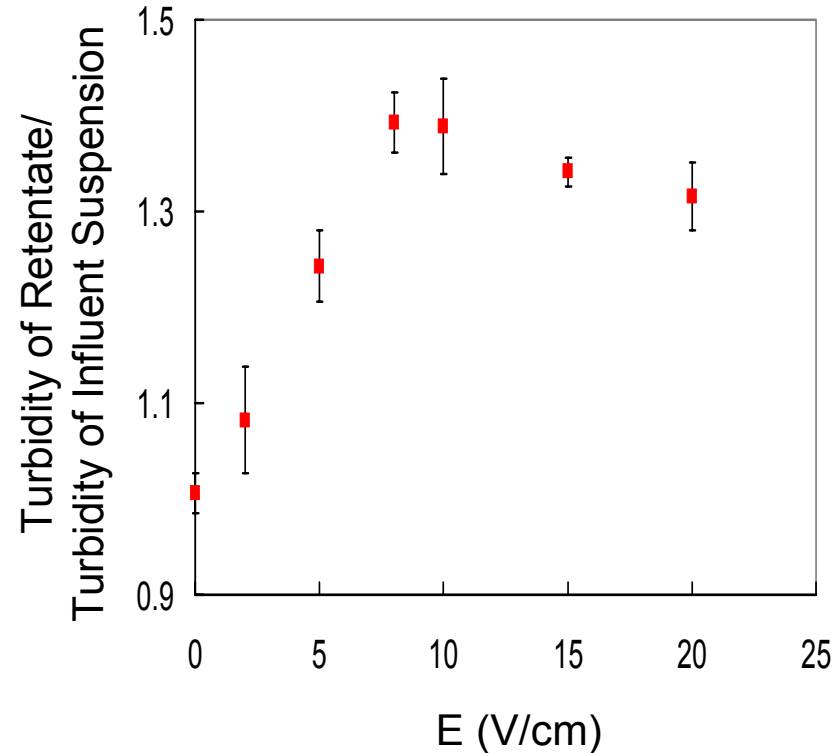
Influent Suspension
Characteristics:
Turbidity = 1550 NTU
Conductivity = 160 $\mu\text{S}/\text{cm}$
pH = 9.0

Electrophoretic Filtration of Particles for Model Copper CMP Waste

Permeate



Retentate



Influent Suspension Characteristics:

[SiO₂] = 900 ppm

[Citric Acid] = 66 ppm

Conductivity = 570 μ S/cm

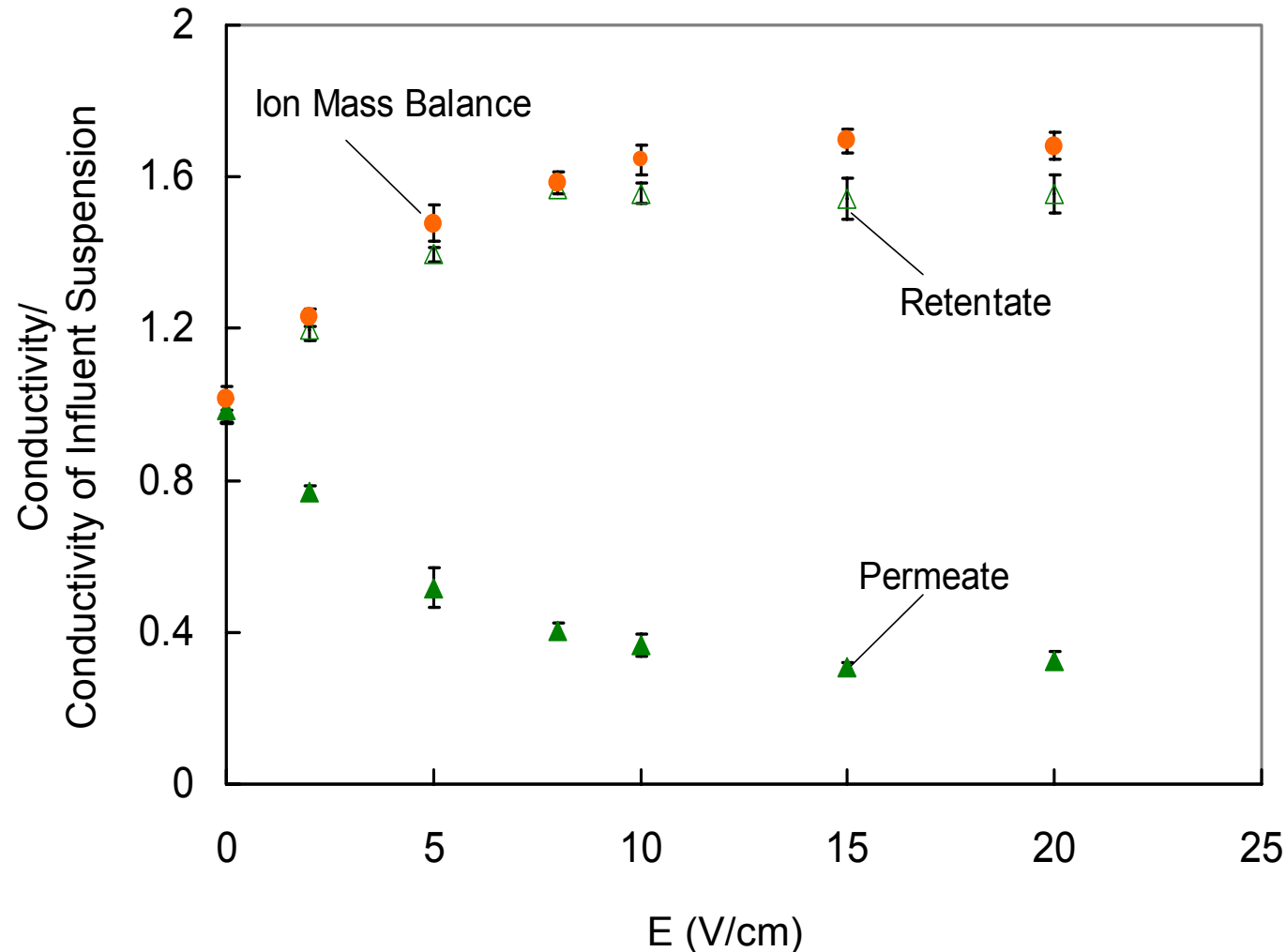
[Cu] = 20 ppm

[BTA] = 37 ppm

Turbidity = 410 NTU

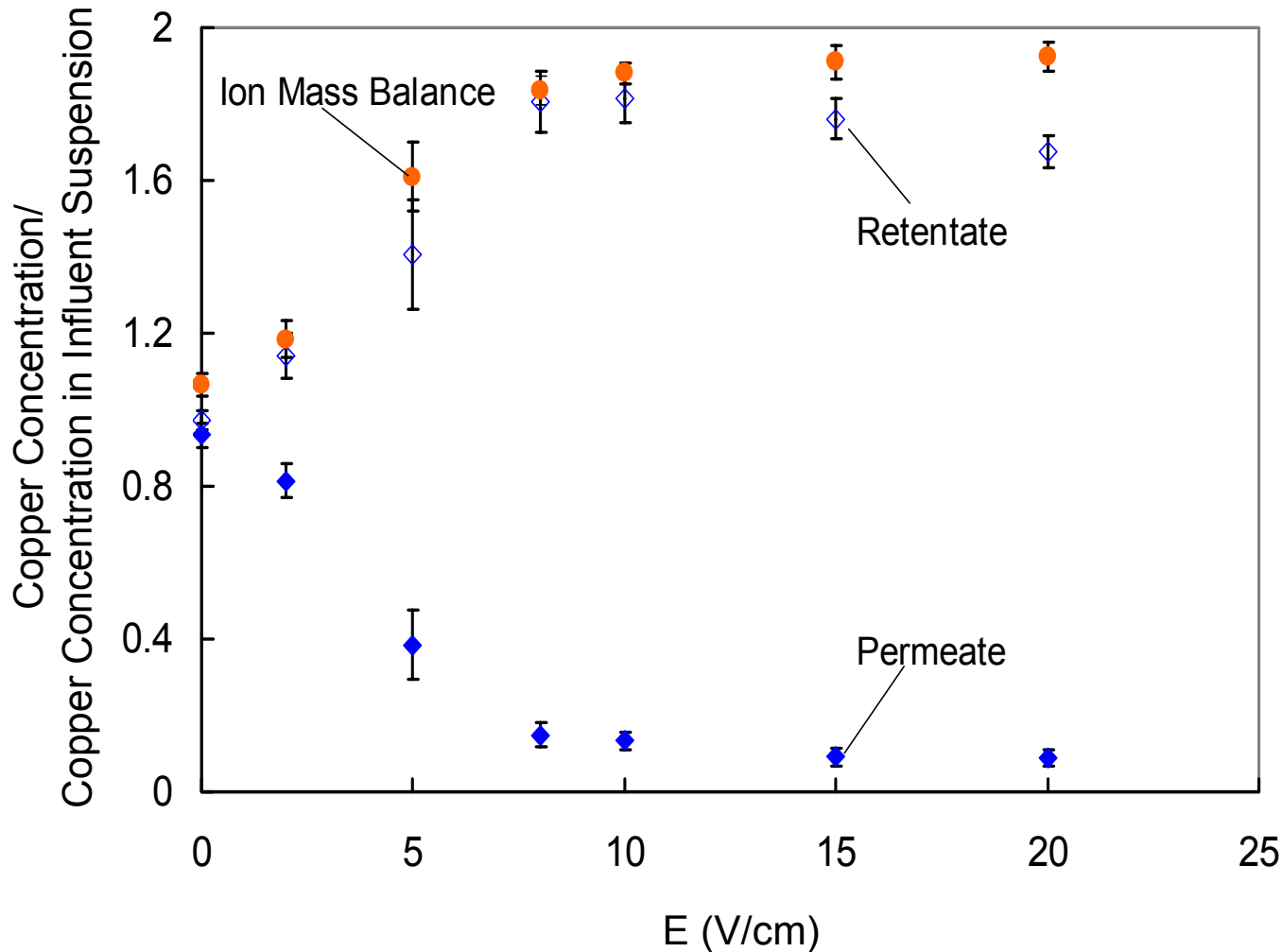
pH = 5.0

Electrodialysis of Ionic Solutes for Model Copper CMP Waste



Influent Suspension
Characteristics:
[SiO₂] = 900 ppm
[Cu] = 20 ppm
[Citric Acid] = 66 ppm
[BTA] = 37 ppm
Turbidity = 410 NTU
Conductivity = 570 μ S/cm
pH = 5.0

Electrodialysis of Copper for Model Copper CMP Waste



Influent Suspension Characteristics:
[SiO₂] = 900 ppm
[Cu] = 20 ppm
[Citric Acid] = 66 ppm
[BTA] = 37 ppm
Turbidity = 410 NTU
Conductivity = 570 μ S/cm
pH = 5.0

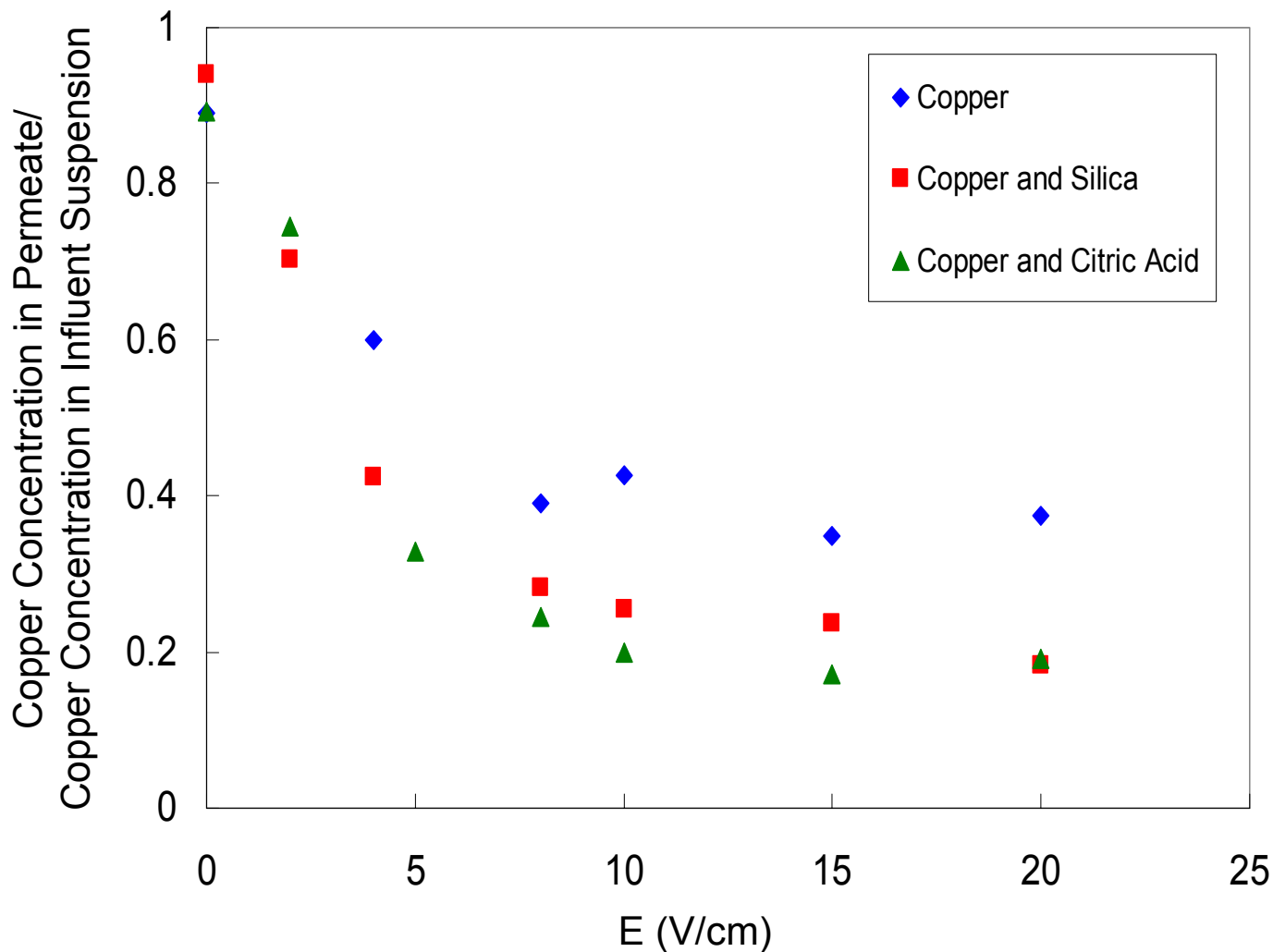
Energy Consumption: Forced-Flow Electrophoretic Filtration vs. Mechanical Filtration

| Filtration Technique | Energy Consumption/ Permeate Flow Rate |
|---|---|
| Ultrafiltration (with 45% pump efficiency) | 5 kJ/gallon of permeate |
| FFE Industrial Oxide CMP Waste Conductivity = 160 $\mu\text{S}/\text{cm}$ | 3 kJ/gallon of permeate |
| FFE Model Copper CMP Waste Conductivity = 570 $\mu\text{S}/\text{cm}$ | 20 kJ/gallon of permeate |

Outline

- Motivation
- Description of Forced-Flow Electrophoresis
- Results
- Additional Research
- Potential Transfer of Technology
- Concluding Remarks

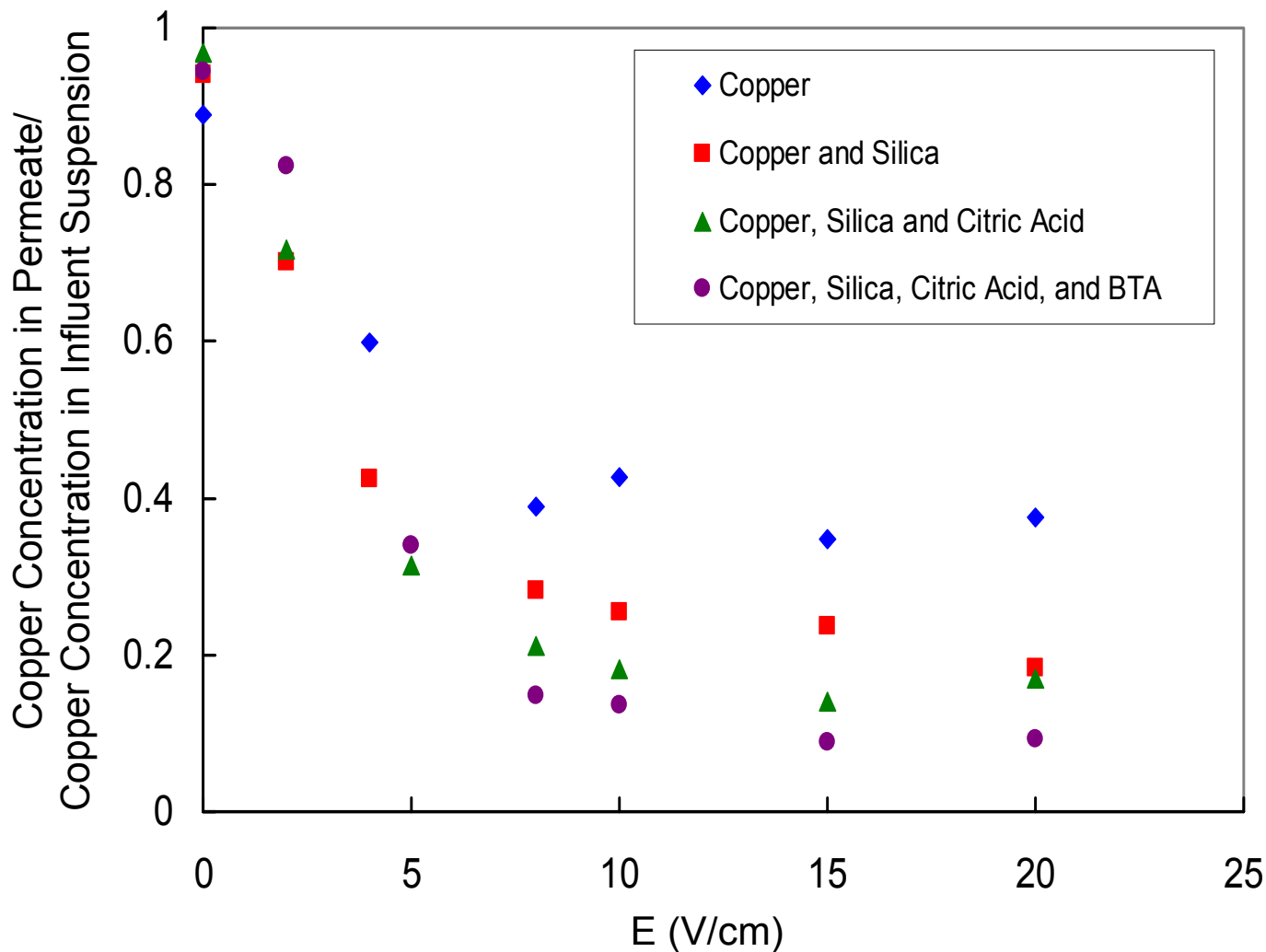
Effects of Various Additives on FFE Process: Electrodialysis of Copper



Influent Suspension
Characteristics:
Conductivity = 570 $\mu\text{S}/\text{cm}$
pH = 5.0

Effects of Various Additives on FFE Process

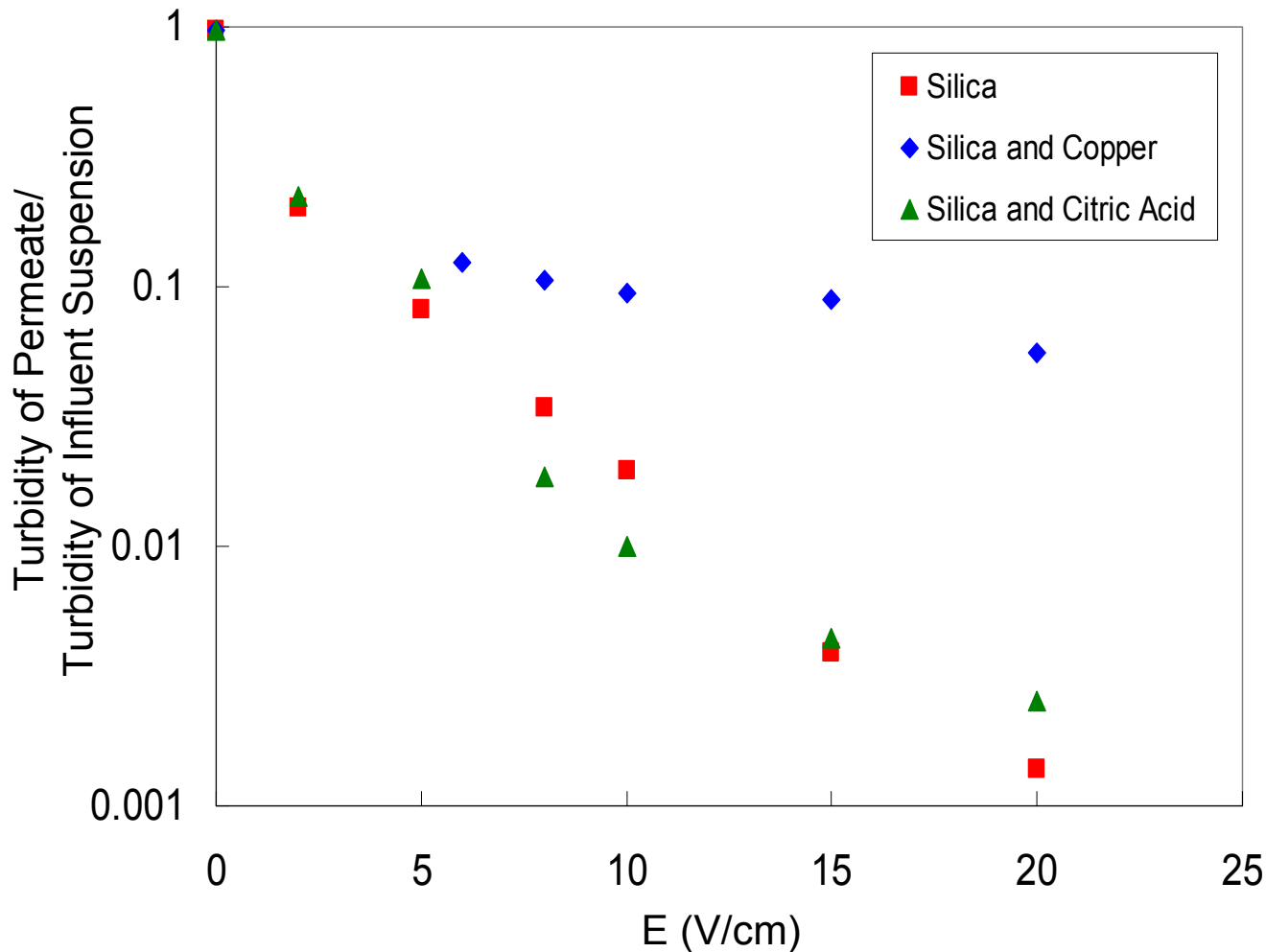
Electrodialysis of Copper (cont.)



Influent Suspension
Characteristics:
Conductivity = 570 $\mu\text{S}/\text{cm}$
pH = 5.0

Effects of Various Additives on FFE Process

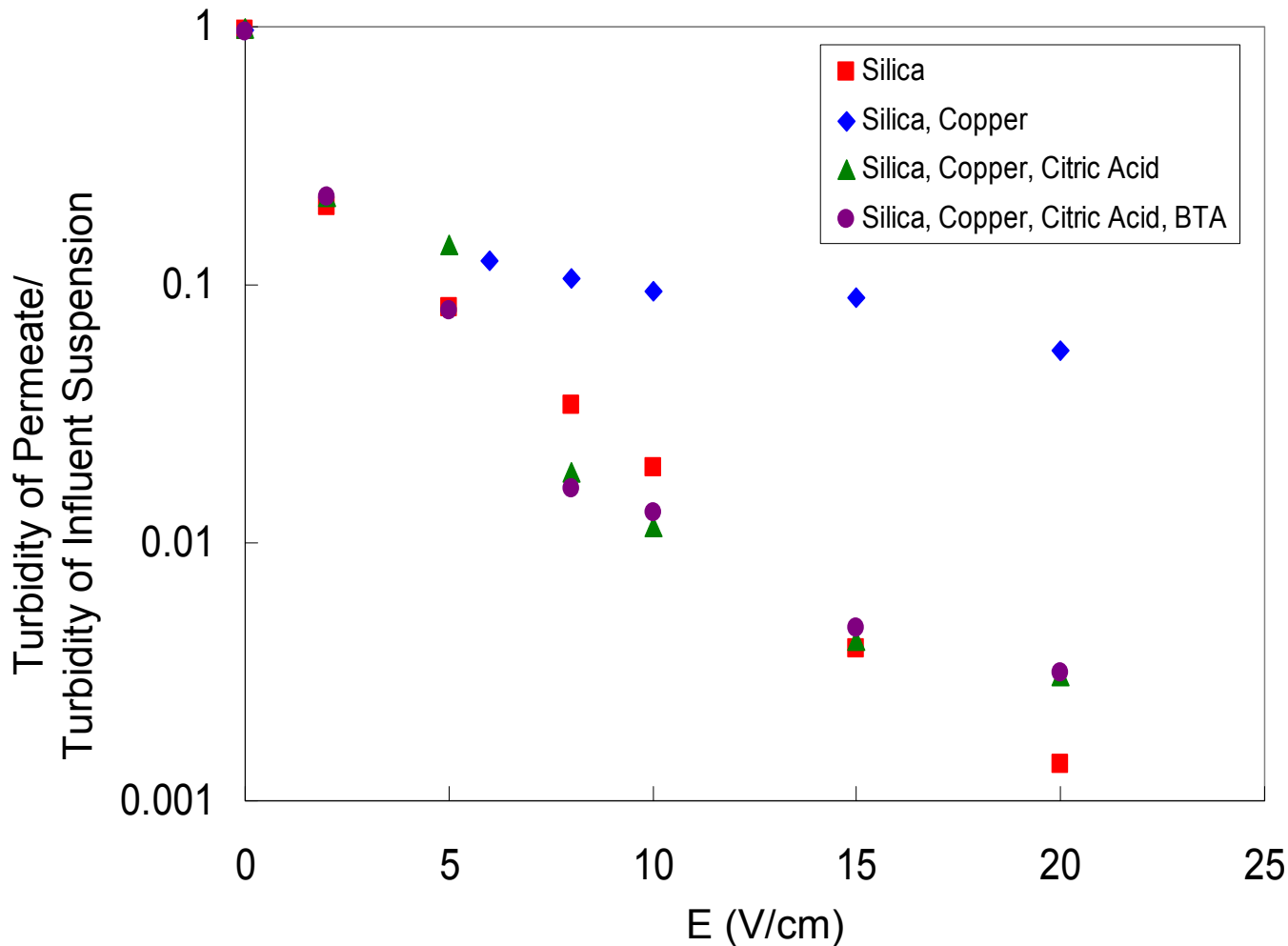
Electrophoretic Filtration of Particles (cont.)



Influent Suspension
Characteristics:
Conductivity = 570 $\mu\text{S}/\text{cm}$
pH = 5.0

Effects of Various Additives on FFE Process

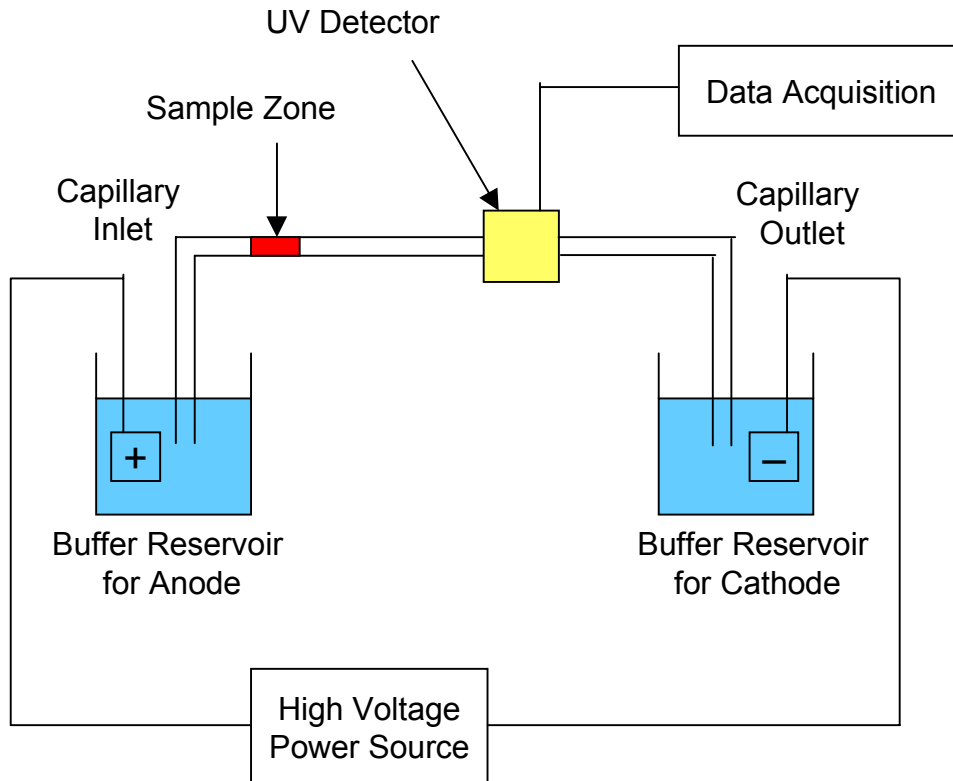
Electrophoretic Filtration of Particles (cont.)



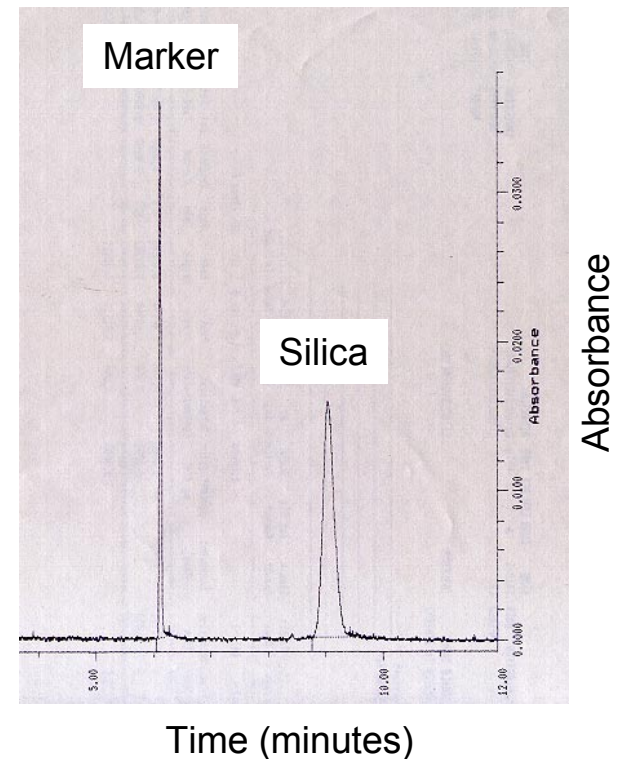
Influent Suspension
Characteristics:
Conductivity = 570 $\mu\text{S}/\text{cm}$
pH = 5.0

Effect of Various Additives on Electrophoretic Mobility of Particles and Copper

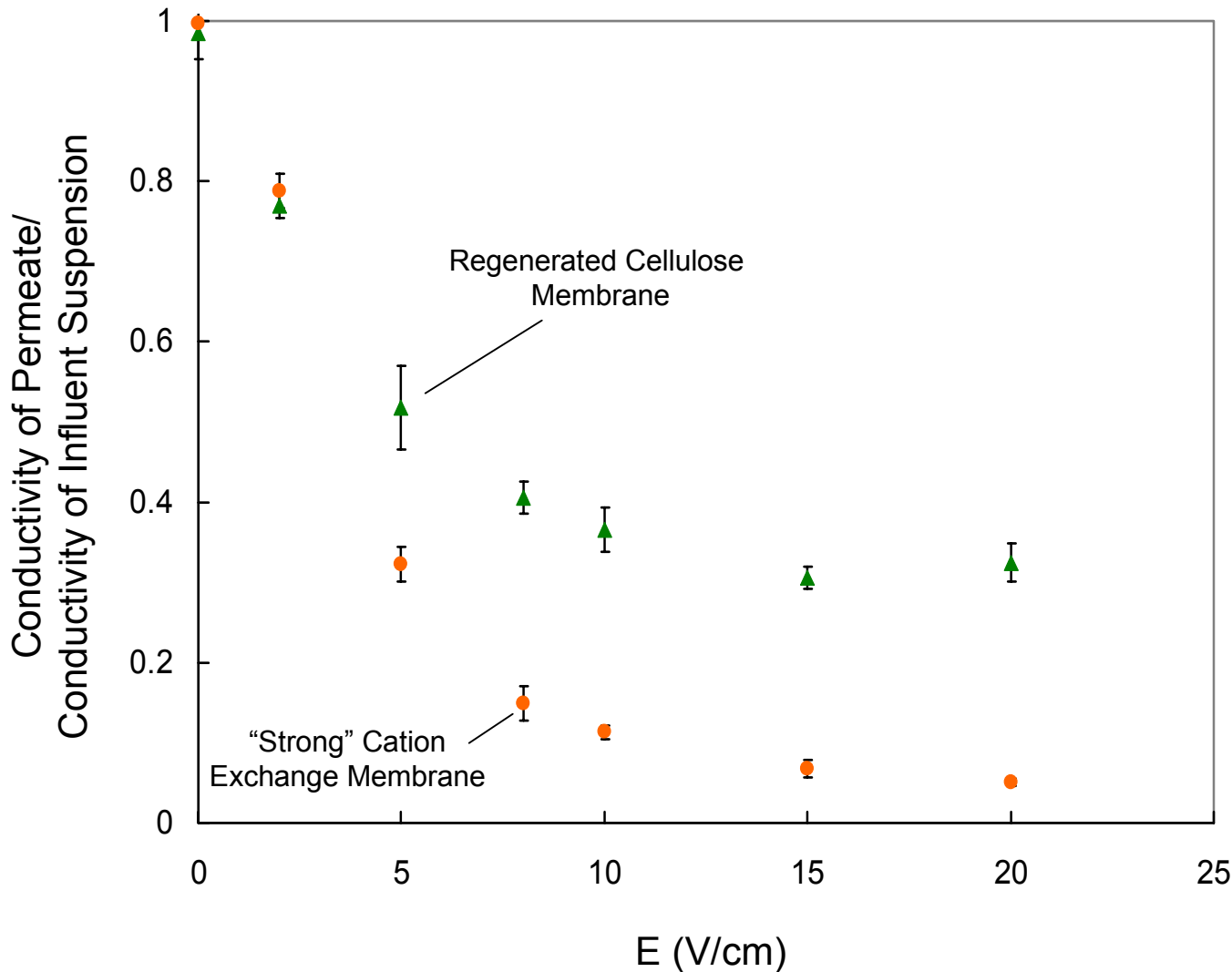
Capillary Electrophoresis



- Additives effect electrophoretic mobilities of particles or copper?
- Additives effect distribution of particle mobilities?



FFE with Strong Cation Exchange Membranes



Influent Suspension

Characteristics:

[SiO₂] = 900 ppm

[Cu] = 20 ppm

[Citric Acid] = 66 ppm

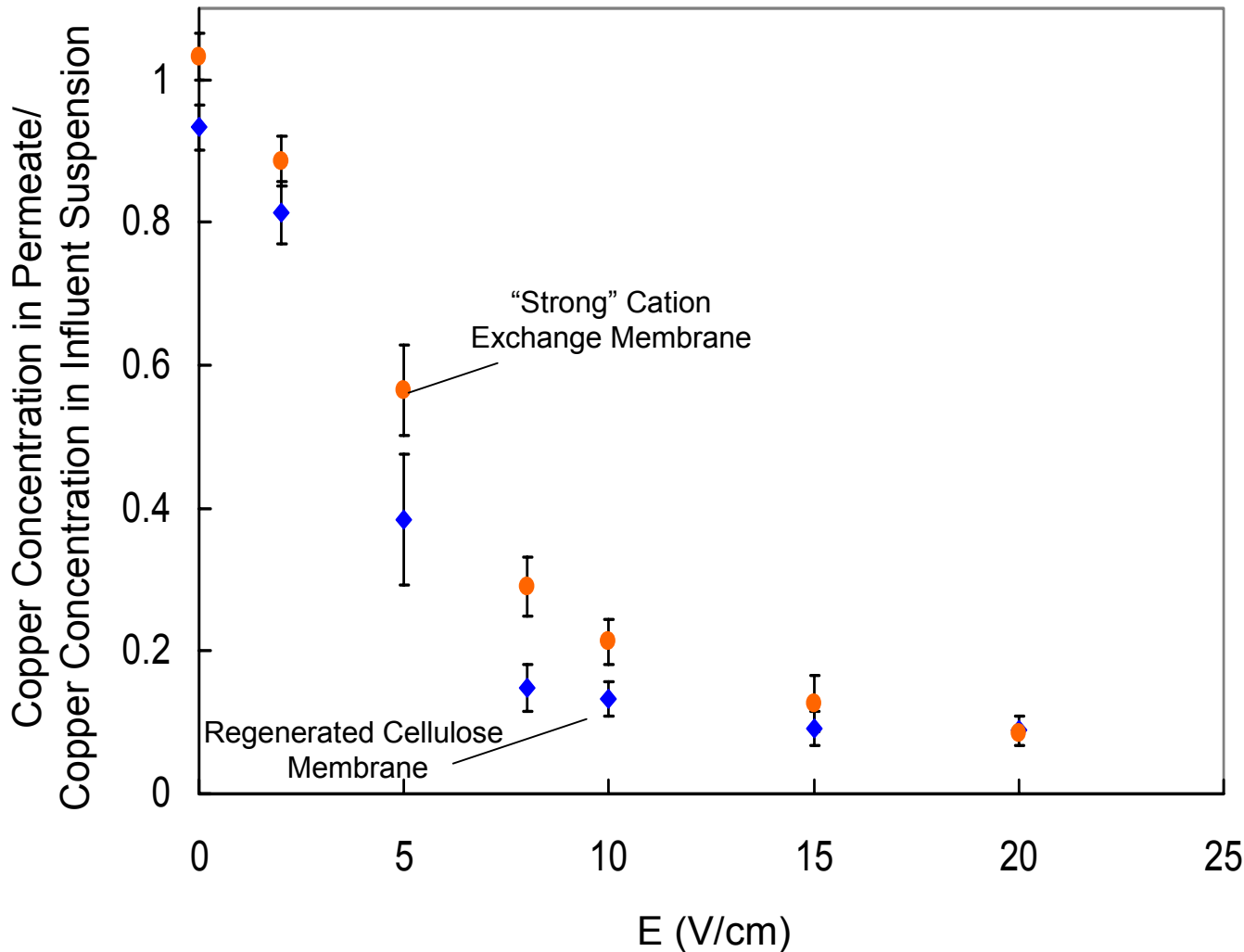
[BTA] = 37 ppm

Turbidity = 410 NTU

Conductivity = 570 μS/cm

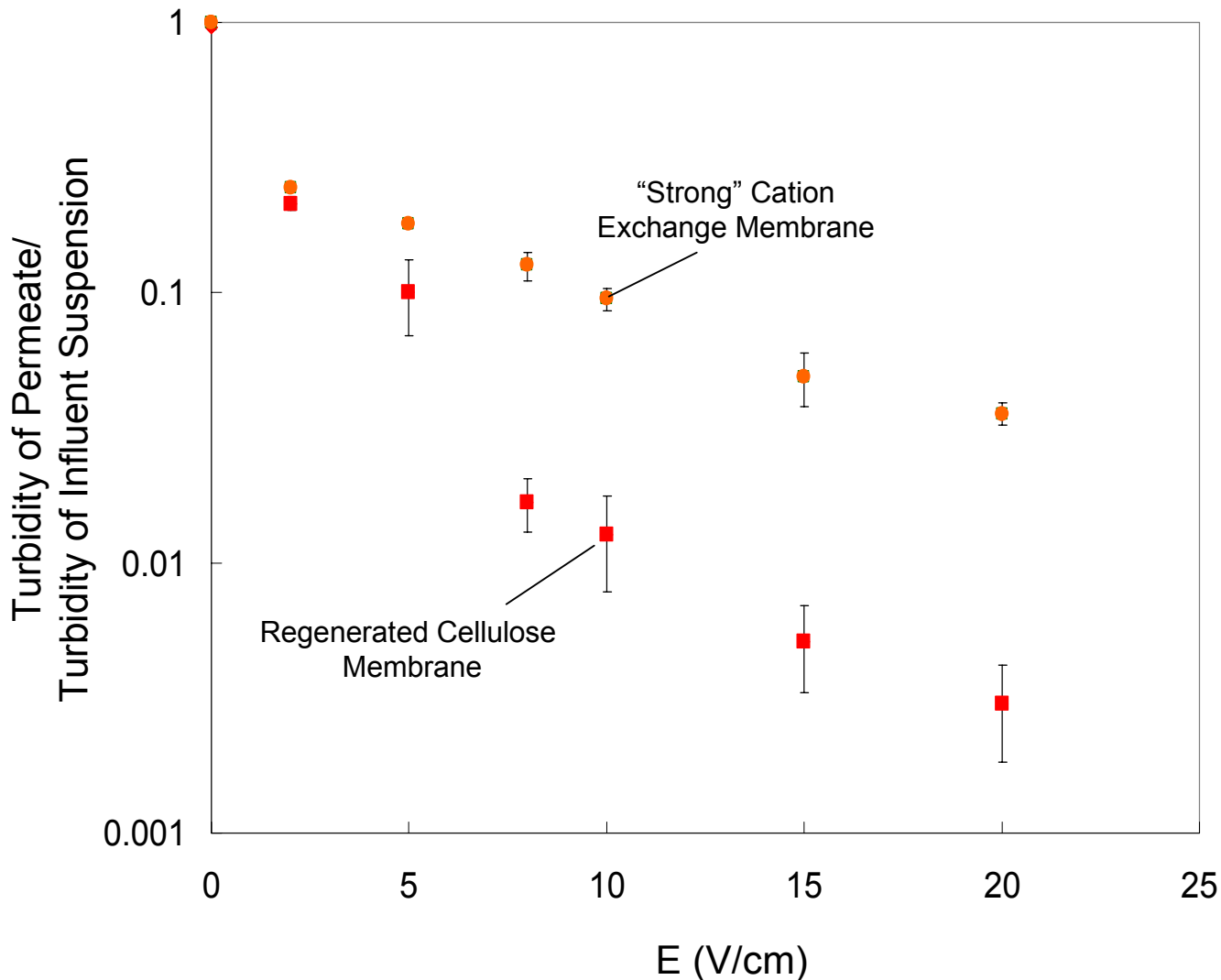
pH = 5.0

FFE with Strong Cation Exchange Membranes (cont.)



Influent Suspension Characteristics:
[SiO₂] = 900 ppm
[Cu] = 20 ppm
[Citric Acid] = 66 ppm
[BTA] = 37 ppm
Turbidity = 410 NTU
Conductivity = 570 μS/cm
pH = 5.0

FFE with Strong Cation Exchange Membranes (cont.)



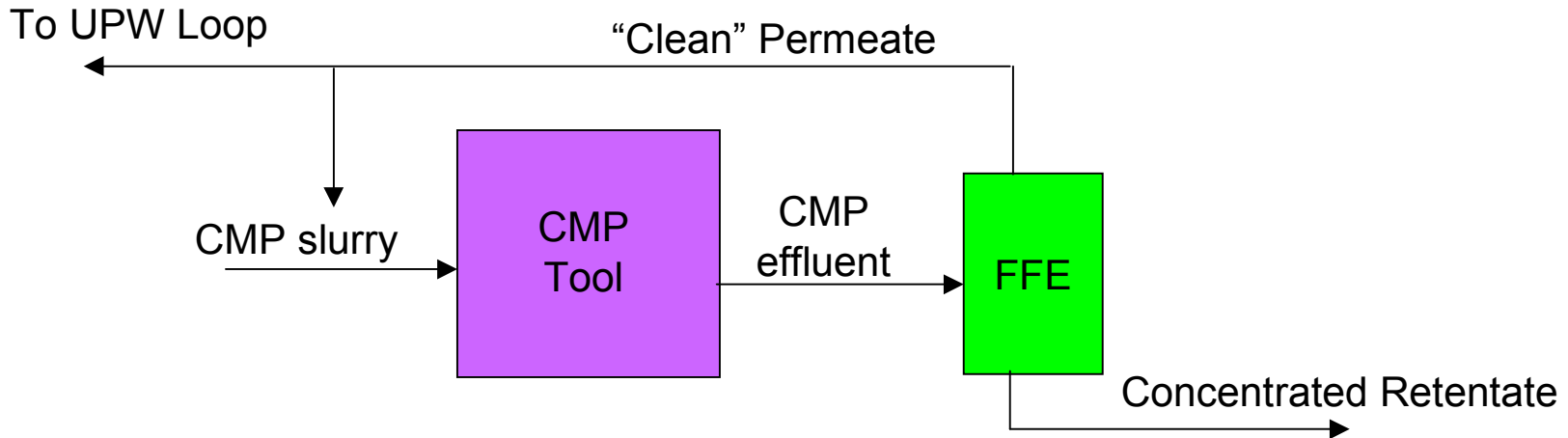
Influent Suspension Characteristics:
[SiO₂] = 900 ppm
[Cu] = 20 ppm
[Citric Acid] = 66 ppm
[BTA] = 37 ppm
Turbidity = 410 NTU
Conductivity = 570 μ S/cm
pH = 5.0

Outline

- Motivation
- Description of Forced-Flow Electrophoresis
- Results
- Additional Research
- Potential Transfer of Technology
- Concluding Remarks

Potential Industrial Applications

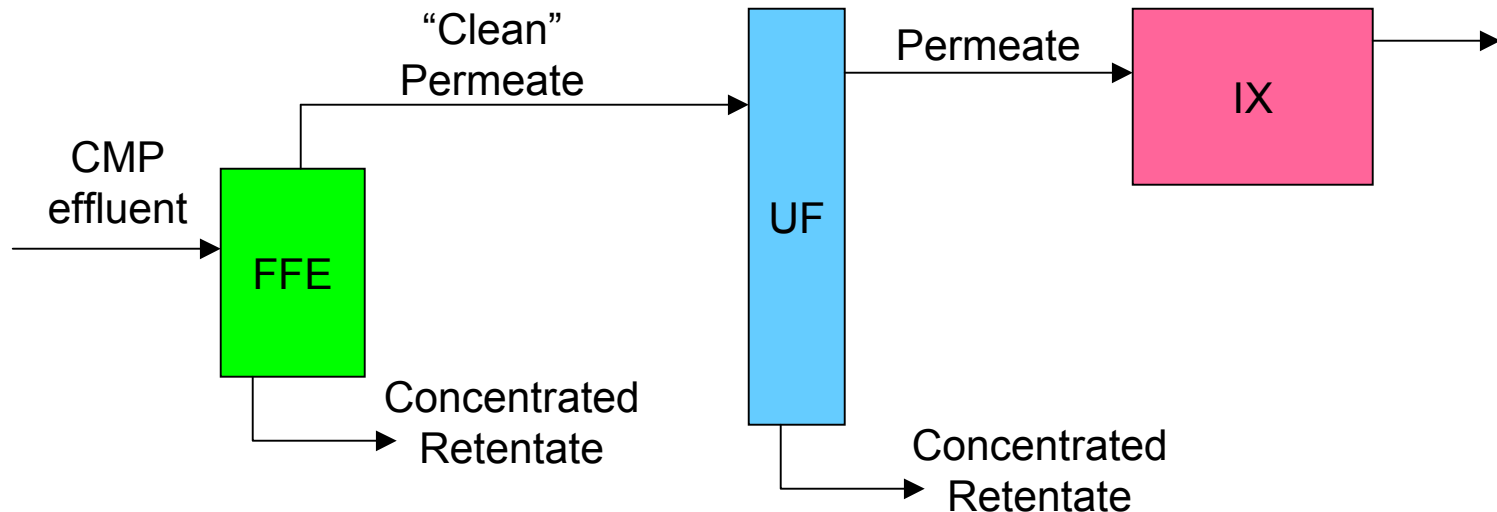
1. Use as filtration device on each individual CMP tool.



- Forced-flow electrophoresis device (FFE) could act as a CMP tool “kidney” that could be switched on and off according to demands of CMP tool.
- Permeate stream, reduced of particle and copper contamination, could be recycled back into the CMP process.

Potential Transfer of Technology (cont.)

- Use immediately before standard ultra-filtration (UF) and ion-exchange (IX) processes to pre-treat CMP waste.



- Forced-flow electrophoresis pre-treatment will yield less consumables (e.g. UF cartridges, ion-exchange resin, etc.)

Industry Interaction

The following companies have provided assistance:

- **Semiconductor Research Corporation**
- **Texas Instruments**, *Jeff Joiner and John DeGenova*
- **Ionics**, *Ted Prato and Russ MacDonald*
- **Pall Corporation**, *Joe O'Sullivan*

Outline

- Motivation
- Description of Forced-Flow Electrophoresis
- Results
- Additional Research
- Potential Transfer of Technology
- Concluding Remarks

Concluding Remarks

- Have demonstrated simultaneous removal of particles (ca. 90 to 99%) and ions (including >85% of Cu) from CMP permeate streams.
- Energy requirements are not significantly different from those of standard ultrafiltration.
- FFE may have the potential to serve as a CMP waste management device and could help the semiconductor industry comply with the environmental regulations for the waste streams.